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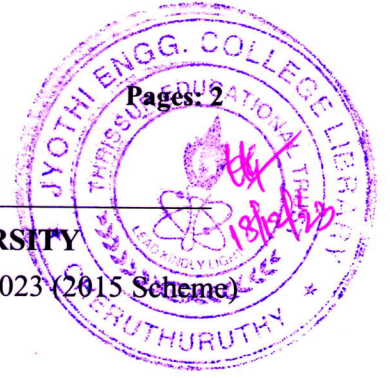
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APJ ABDUL KALAM TECHNOLOGICAL UNIVERSITY

B.Tech Degree S3 (S, FE) / S1 (PT) (S, FE) Examination December 2023 (2015 Scheme)



Course Code: EC203

Course Name: SOLID STATE DEVICES (EC, AE)

Max. Marks: 100

Duration: 3 Hours

PART A

Answer any two full questions, each carries 15 marks.

Marks

- 1 a) Explain the temperature dependence of carrier concentration of an extrinsic semiconductor (7)
- b) A Si sample with $10^{16}/\text{cm}^3$ donors is optically excited such that $10^{19}/\text{cm}^3$ electron-hole pairs are generated per second uniformly in the sample. The laser causes the sample to heat up to 450K. Find the quasi-Fermi levels and the change in conductivity of the sample upon shining the light. Electron and hole life times are both $10 \mu\text{s}$, $D_p = 12 \text{ cm}^2/\text{s}$, $D_n = 36 \text{ cm}^2/\text{s}$, $n_i = 10^{14} \text{ cm}^{-3}$ at 450 K. What is the change in conductivity upon shining light? (8)
- 2 a) Explain the variation of mobility with temperature and doping. (7)
- b) Derive the continuity equation for holes and electrons in a semiconductor. Find the expression for steady state diffusion equations for holes and electrons. (8)
- 3 a) Derive the expression for conductivity and mobility of carriers in a semiconductor subjected to an electric field. (7)
- b) Show that diffusion length is the average distance a carrier diffuses before it recombines. (8)

PART B

Answer any two full questions, each carries 15 marks.

- 4 a) List the assumptions and derive Ideal Diode equation (9)
- b) Explain the different types of capacitances associated with a p-n junction. (6)
- 5 a) Boron is implanted into an n-type Si sample ($N_d = 10^{16} \text{ cm}^{-3}$), forming an abrupt junction of square cross section with area $2 \times 10^{-3} \text{ cm}^2$. Assume that the acceptor concentration in the p type region is $N_a = 4 \times 10^{18} \text{ cm}^{-3}$. Calculate V_o , X_{no} , X_{po} , Q^+ and E_o for this junction at equilibrium (300K). (9)
- b) Explain the operation of a tunnel diode with appropriate energy band diagram. (6)

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- 6 a) Draw the energy band diagram of a p-n junction at a) equilibrium b) Forward bias (9)
c) Reverse bias.
- b) With the help of energy band diagrams, explain metal- n type Ohmic contact. (6)

PART C

Answer any two full questions, each carries 20 marks.

- 7 a) Draw the minority carrier distribution in PNP transistor in saturation mode and explain. (5)
- b) The following parameters are given for a transistor $I_{pE} = 0.678 \text{ mA}$, $I_{nE} = 2.712 \times 10^{-6} \text{ A}$, $I_{pC} = 0.6779 \text{ mA}$, $I_{nC} = 9.4 \times 10^{-15} \text{ A}$. Determine emitter injection efficiency and base transport factor. (5)
- c) Draw and explain the C-V Characteristics of an Ideal MOS capacitor. Derive the expression for threshold voltage. (10)
- 8 a) Define the basic performance parameters of BJTs. (5)
- b) Explain Base width modulation. (5)
- c) With the help of necessary band diagrams, explain equilibrium, accumulation, depletion and inversion stages of a MOS capacitor. (10)
- 9 a) Derive the expression for terminal currents of a transistor. List the assumptions made for the derivation. (10)
- b) Explain the principle of operation of FinFET (5)
- c) Explain sub threshold characteristics of MOSFET (5)
